

Corrigendum/Erratum

Intrinsically low-resistance carbon nanotube-metal contacts mediated by topological defects – CORRIGENDUM/ERRATUM

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In H.S. Kim et al.¹, capped carbon nanotube models were mislabeled several times.

On page 3, third paragraph, line 7, “41 k Ω for *cap3*” should read “41k Ω for *cap6*.”

On page 5, second paragraph, lines 8–9, “why *cap1* is a better metallic contact than *cap6*” should read “why *cap6* is a better metallic contact than *cap1*.”

The authors regret the error.

In addition, the order of authors was incorrect as published. The correct author order is as follows: Han Seul Kim, Ga In Lee, Hu Sung Kim, Jeung Ku Kang, and Yong-Hoon Kim.

The publisher regrets the error.

Reference

1. H.S. Kim, H.S. Kim, G.I. Lee, J.K. Kang, and Y-H. Kim: Intrinsically low-resistance carbon nanotube-metal contacts mediated by topological defects. *MRS Comm.* **2**(3), (2012)